



ORGANISATION FOR ECONOMIC
CO-OPERATION AND DEVELOPMENT

ENVIRONMENT DIRECTORATE
Environment, Health and Safety Division

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Paris, 14 September 2007

To: Heads of Delegation to the Working Party on Manufactured Nanomaterials (WPMN)

Cc: ENV Counsellors to OECD Permanent Delegations

Questionnaire for national authorities (and other delegations to the WPMN) responsible for the safety of manufactured nanomaterials
[Responses requested: on or before 19th October 2007]

Dear Colleagues,

You will recall that the 2nd meeting of the Working Party on Manufactured Nanomaterials (WPMN) agreed that a questionnaire/ information request be prepared. The attached questionnaire has been prepared based on the information needs as identified by the six steering groups responsible for the development of each project of the WPMN.

The main objective of this questionnaire is to collect information that will be used in implementing the projects of the WPMN. The questionnaire is targeted at delegations to the WPMN who have an interest in the safety of manufactured nanomaterials. It is expected that delegations will also forward it to other stakeholders in their countries who might be in a position to address some of the issues.

I am now pleased to attach a copy of the **Questionnaire for national authorities (and other delegations to the WPMN) responsible for the safety of manufactured nanomaterials**, which has been prepared by the Bureau of the WPMN together with the Chairs of the six projects. **I would be grateful for your response by 19th October 2007.** I would also welcome any documentation or reference materials which you might wish to include with your responses.

Please send your completed responses to Diana Morales (e-mail Diana.morales@oecd.org). The deadline for responses is **19th October 2007**. If you have any enquiries concerning this questionnaire, please also contact Diana Morales.

Yours sincerely,

A handwritten signature in black ink, appearing to read 'Peter Kearns', written over a large, stylized flourish.

Peter Kearns